

Notice of References Cited	Application/Control No. 10/535,317		Applicant(s)/Patent Under Reexamination XU ET AL.	
	Examiner Mark L. Shevin		Art Unit 1793	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-6,325,868	12-2001	Kim et al.	148/403
*	B	US-2002/0003013	01-2002	Hays, Charles C.	148/561
*	C	US-2003/0140987	07-2003	Bae et al.	148/403
*	D	US-2006/0231169	10-2006	Park et al.	148/403
*	E	US-2006/0237105	10-2006	Yim et al.	148/403
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N	CN 1354274	06-2002	China	Zhao	C22C 45/04
	O	TW 458828	10-2001	Taiwan	Li	B22F 1/00
	P					
	Q					
	R					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	T.G. Park, Development of new Ni-based amorphous alloys containing no metalloid that have large undercooled liquid regions, Scripta mater 43, (2000), p. 109-114.
	V	M.H. Lee et al. Quaternary and quinary Ni-based amorphous alloys in the 3Ni-Zr-Ti-X (X=Al,Si,P) and Ni-Zr-Ti-Si-Y (Y=Sn, Mo, Y) systems. Mat. Res. Soc. Symp. Proc., Vol. 644, (2001) L4.8.1 – L4.8.6.
	W	
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.